

DO NOT ENTER: /CAM/

PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Serial No.: 10/797,876
Applicant: Dip et al.
Filing Date: March 10, 2004
Art Unit: 2811
Examiner: Colleen Matthews
Title: **SILICON GERMANIUM SURFACE LAYER FOR HIGH-K
DIELECTRIC INTEGRATION**
Attorney Docket: TPS-007
Confirmation No.: 5070

August 10, 2009

Mail Stop AF
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

RESPONSE TO FINAL REJECTION

This paper is responsive to the Office Action mailed June 10, 2009. The present response includes the following:

Amendments to the Specification:	Page 2
Amendments to the Claims:	Pages 3–7
Amendments to the Abstract:	None
Amendments to the Drawings:	Page 8
Remarks:	Pages 9–17
Attachments:	Drawing Replacement Sheet